

# Strategies for ultra-low Ag consumption for industrial n-type cells

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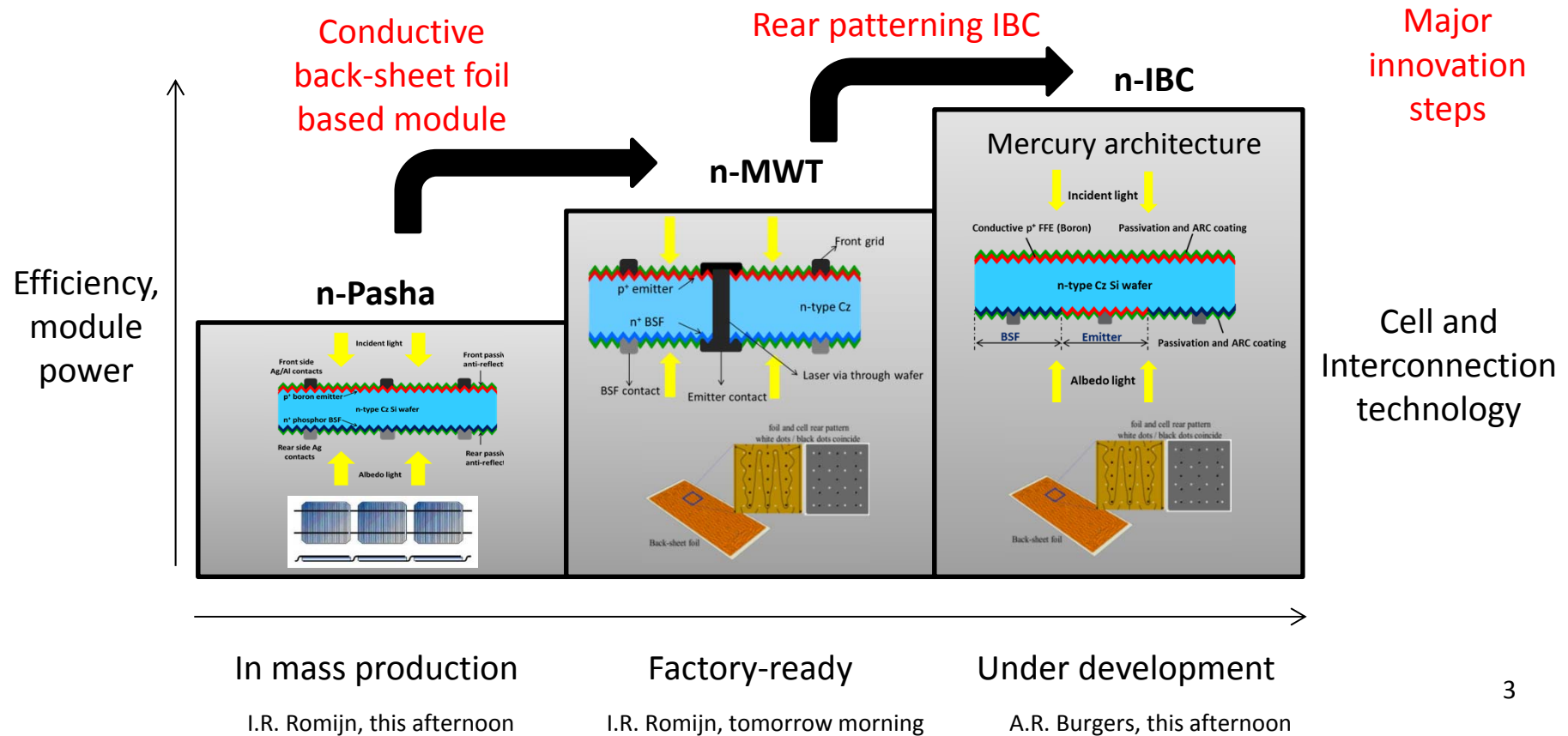


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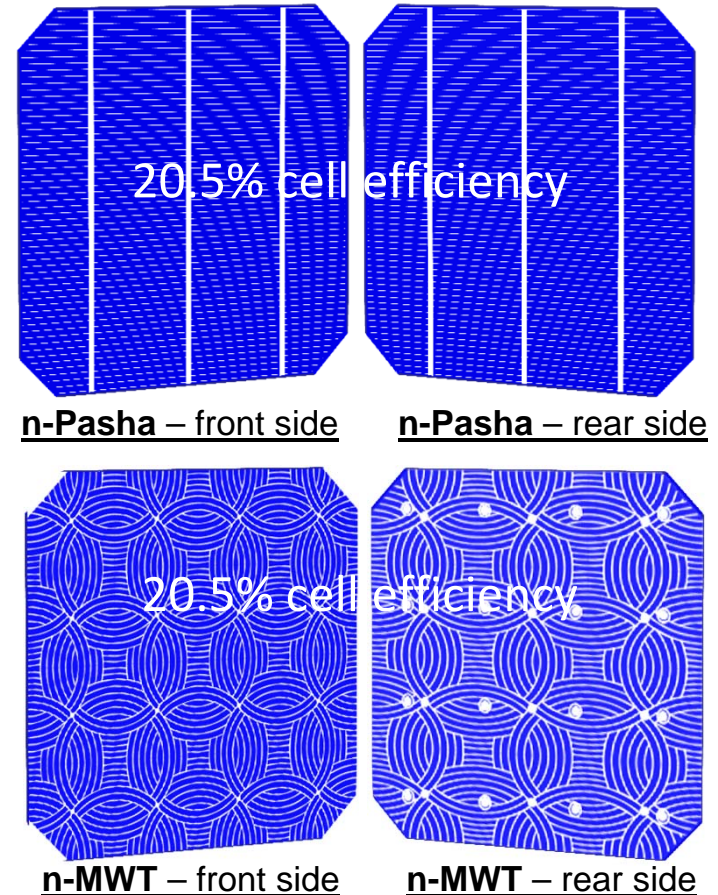
Barry O'Sullivan, Maarten Dubucquoy

# ECN n-type technology platform

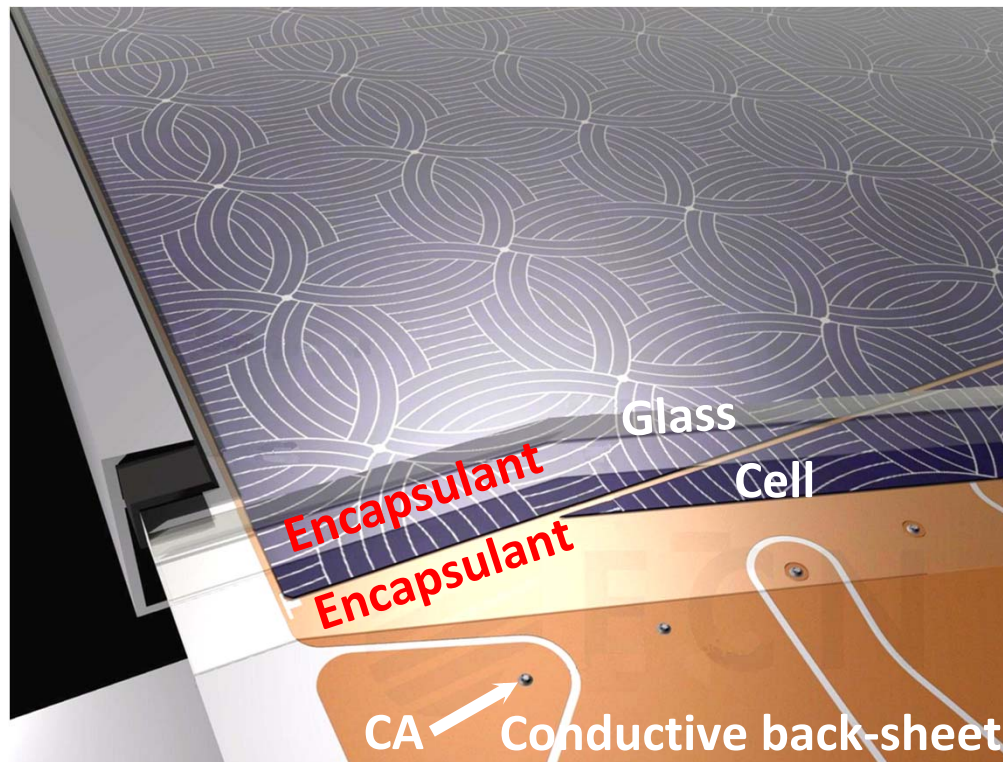


# ECN n-type cell technology

- Rear-passivated bifacial cells
  - Front boron emitter and phosphorus BSF
- n-Pasha<sup>(1)</sup>
  - Passivated both sides with H-pattern grids
  - Front and rear tabbed interconnection
- n-MWT<sup>(2)</sup>
  - Metal wrap through of front side grid to rear contacts
  - Module interconnection on the rear
- Simple and industrial process steps
- Both n-Pasha and n-MWT reach 20.5%
  - Presentations: <sup>(1)</sup>I.G. Romijn et al., We. afternoon
  - <sup>(2)</sup>I.G. Romijn et al., Thu. morning



# ECN back contact module technology\*



CA: conductive adhesive

- Low cell-to-module loss
- Low stress on wafers
  - no tabbing, no soldering
  - suitable for very thin wafers
- Higher packing density of cells
- Combined lamination and interconnection

# Sustainability of PV



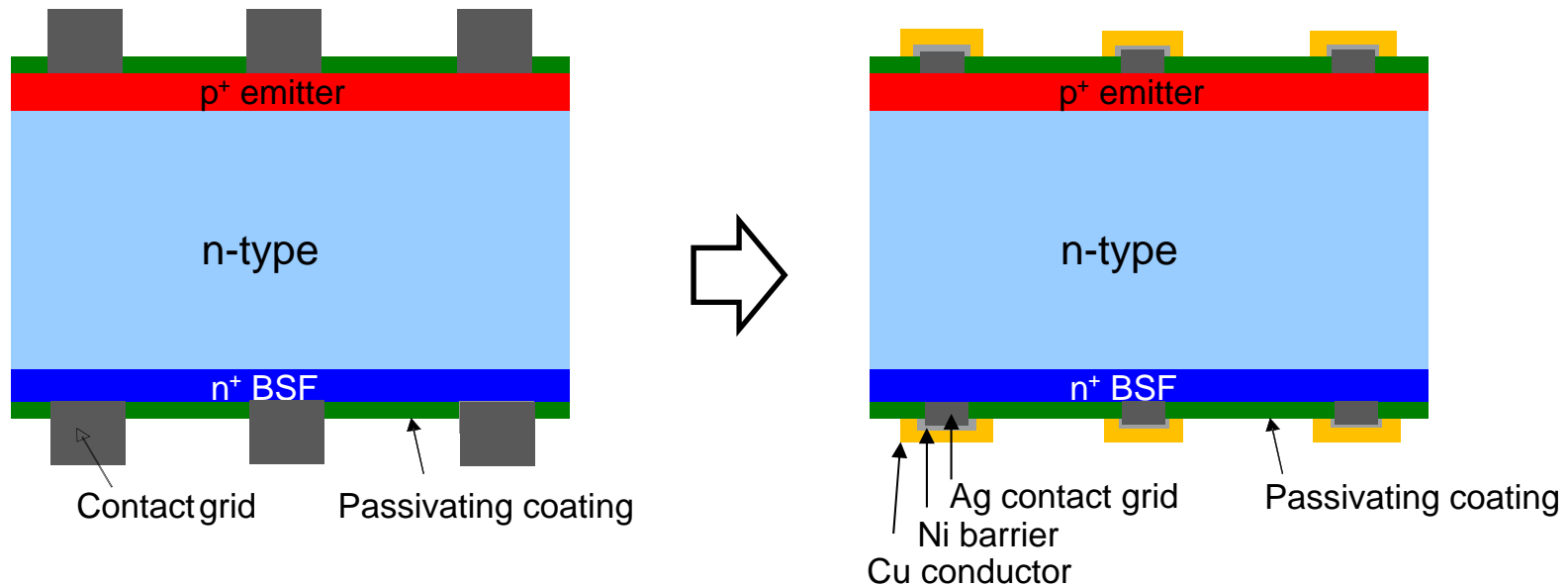
- Key sustainability parameters of c-Si PV are:
  1. Use of Ag for metallisation (cost, resource depletion)
  2. Energy for production of silicon wafer (cost, CO<sub>2</sub> footprint)
  3. Recyclability of PV modules (recovery of materials, CO<sub>2</sub> footprint)
- Efforts in the Cu-PV project:
  1. Ag reduction for metallisation
  2. Very thin cells with all contacts on the rear (MWT, IBC)
  3. Back-contact module technology, designed for recycling
- This presentation covers methods and progress in Ag reduction
  - Demonstrator devices: n-Pasha and n-MWT cells and modules





# Ag reduction by seed & plate

- Based on established firing-through metallisation
- $\Rightarrow$  *Inkjet* printing of seed grids allows minimal Ag consumption and fine lines
- $\Rightarrow$  *Electroplating* of Ni barrier, Cu conductor, and capping layer



## Seed & plate front side

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- 86 fingers, seed Ag consumption between 3.6 and 7.2 mg Ag
- 3 busbars 1.5mm width, 6.2mg Ag



Inkjet printed finger before plating  
3.6 mg Ag for 86 fingers

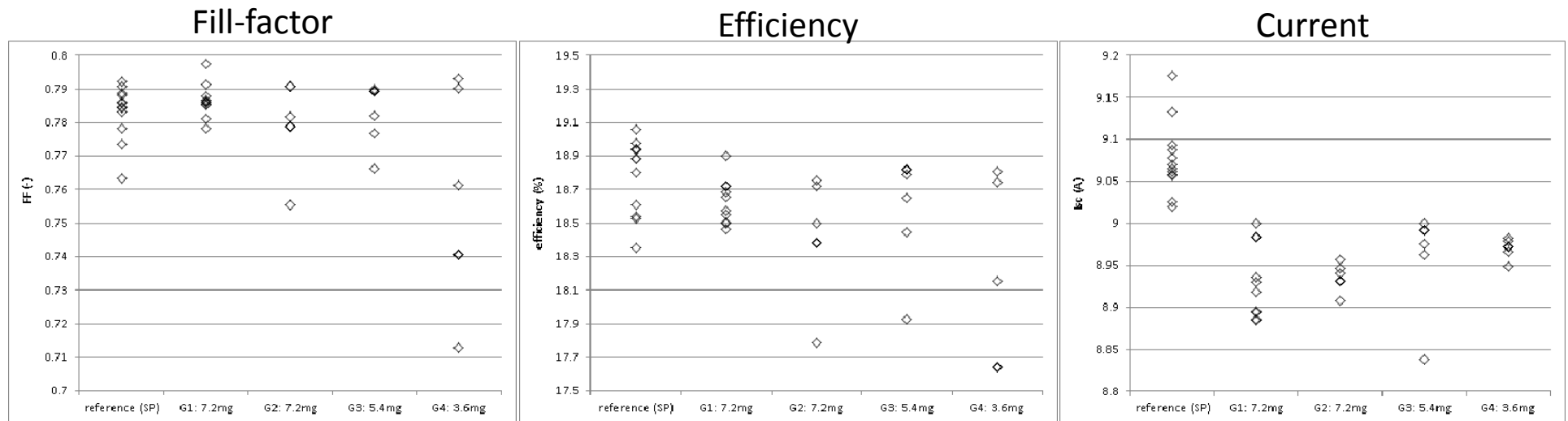


After NiCu plating (2+8  $\mu\text{m}$ ):  
width 55-60  $\mu\text{m}$



# Seed & plate front side

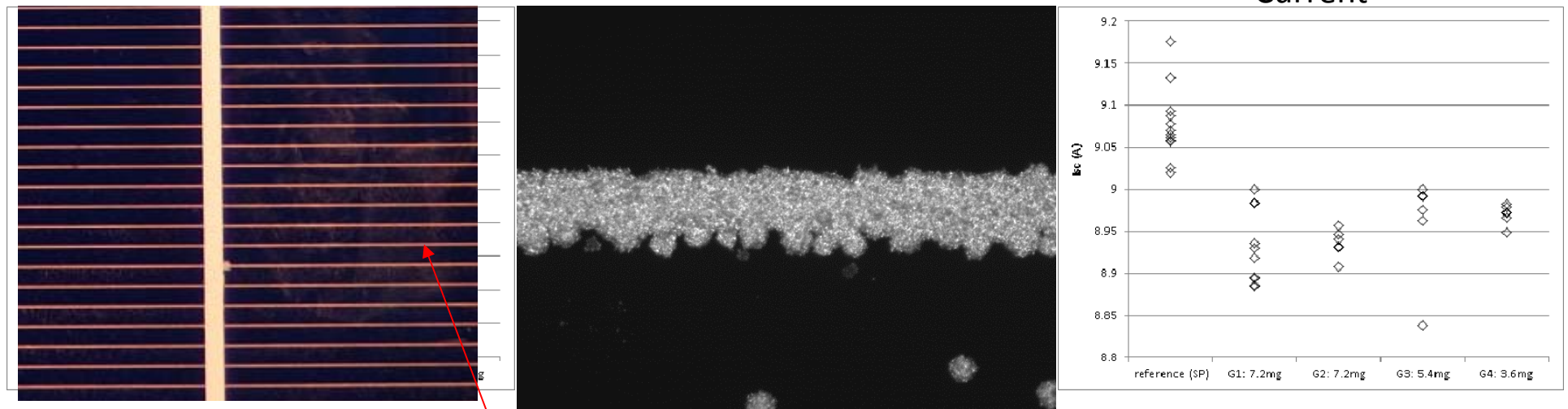
- 86 fingers, seed Ag consumption between 3.6 and 7.2 mg Ag



- FF comparable to reference for seed Ag consumption of 7.2 or 5.4 mg
- scatter in FF increases for seed Ag consumption of 3.6mg

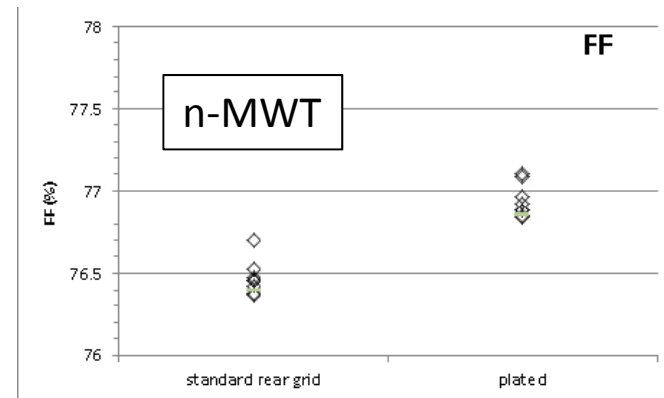
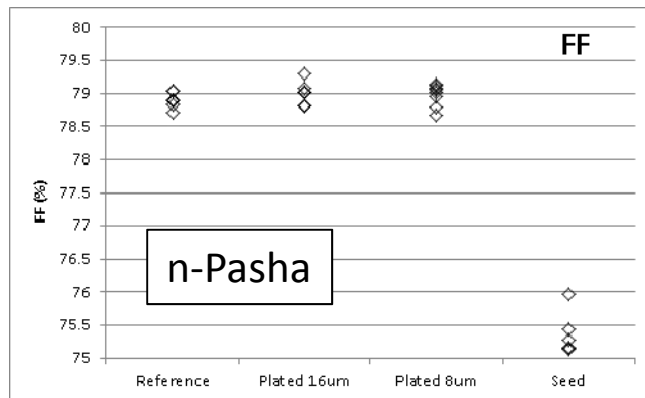
# Seed & plate front side

- 86 fingers, seed Ag consumption between 3.6 and 7.2 mg Ag



# Seed & plate rear side

- Benefits: Ag reduction and FF increase
- No efficiency penalty from wide fingers or ghost plating
- Screen print seed: at least 75% Ag reduction
- FF gain about 0.2-0.4%<sub>abs</sub>, depending on plating thickness

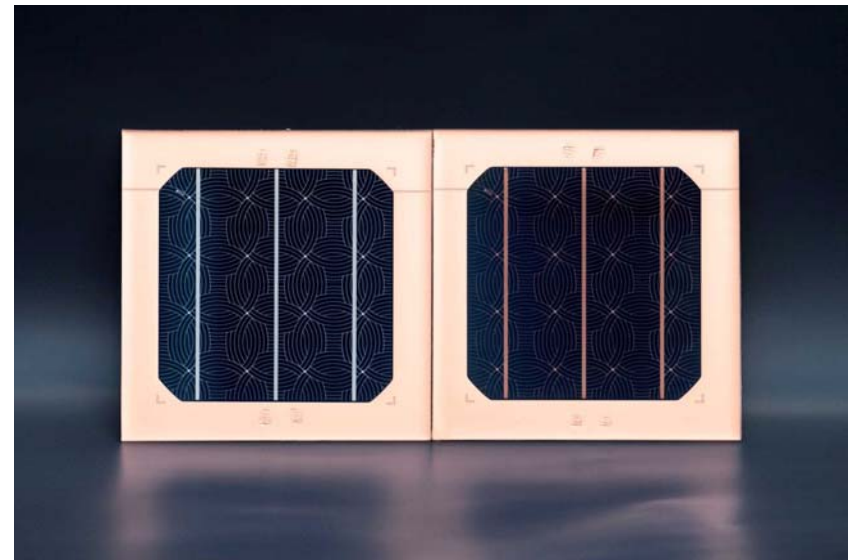


- Inkjet seed: in progress. At least 90% Ag reduction.

# Copper-plated MWT cells in modules

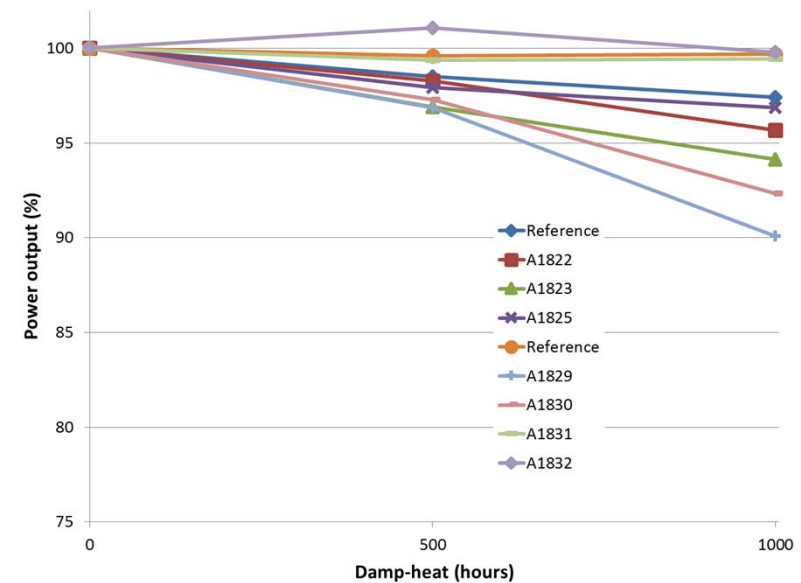
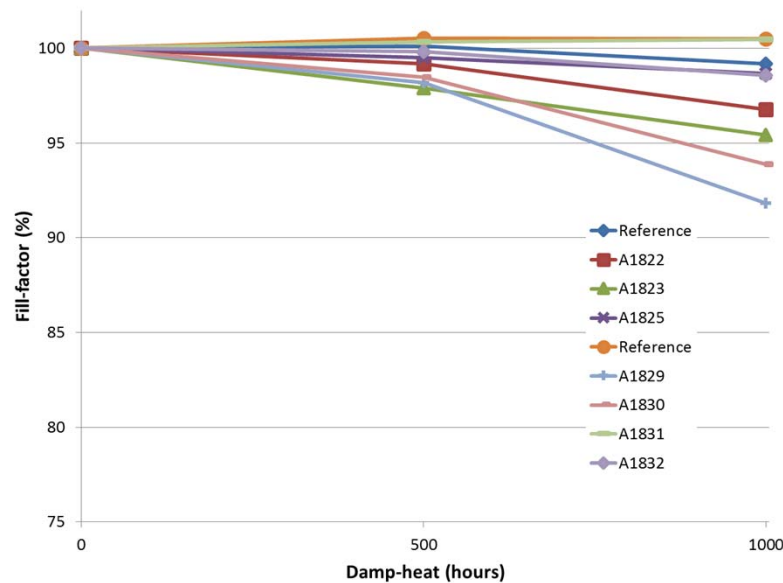


- Single cell modules with copper plated MWT cells
- Initial test with several configurations
  - Front, back and both side plated
  - EVA and alternative encapsulants
  - Qualified conductive adhesive
- Modules characterized and subjected to climate chamber testing



Module with plated cell right,  
reference module left

# Results damp-heat testing



- Degradation within 5% limit for most modules
- No obvious influence of encapsulant on degradation rate
- No significant difference between cell types

# Conclusions

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- Seed & plate metallisation with copper gives a 70-90% reduction in Ag consumption
- Efficiency similar to fired Ag metallisation
  - Improvement in current will be made through tuning and clean processing
  - Plating of the rear side results in an improved fill-factor
- Cells compatible with back-contact module processing
- Modules show promising performance in accelerated testing



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